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(54) **HEATER ELECTRICAL CONNECTOR AND ADAPTER**

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CPC F21L 4/08; F21V 3/00; F21V 29/00; F21V 29/70; H01J 5/54; H01J 13/46; H01J 61/52; H01R 13/44; H01R 13/52; H01R 13/62; H01R 13/627; H01R 13/64; H01R 13/645; H01R 33/02; H01R 33/22; H01R 33/46

See application file for complete search history.

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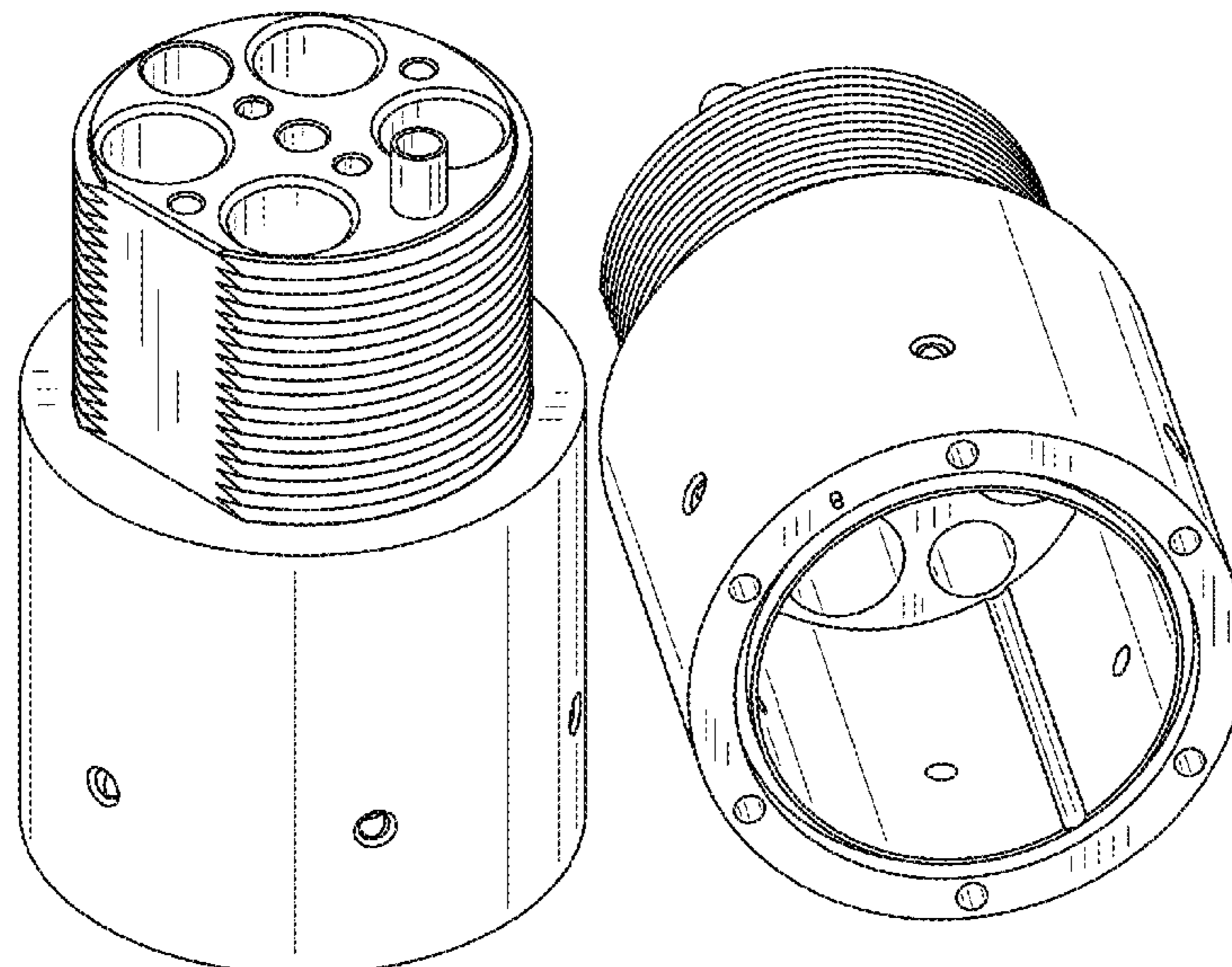
(57) **CLAIM**

The ornamental design for a heater electrical connector and adapter, as shown and described.

DESCRIPTION

FIG. 1 is an isometric view of a heater electrical connector and adapter in accordance with the design; FIG. 2 is a bottom isometric view thereof; FIG. 3 is a front view thereof; FIG. 4 is back view thereof; FIG. 5 is a right side view thereof; FIG. 6 is a left side view thereof; FIG. 7 is a top view thereof; and, FIG. 8 is a bottom view thereof.

1 Claim, 7 Drawing Sheets



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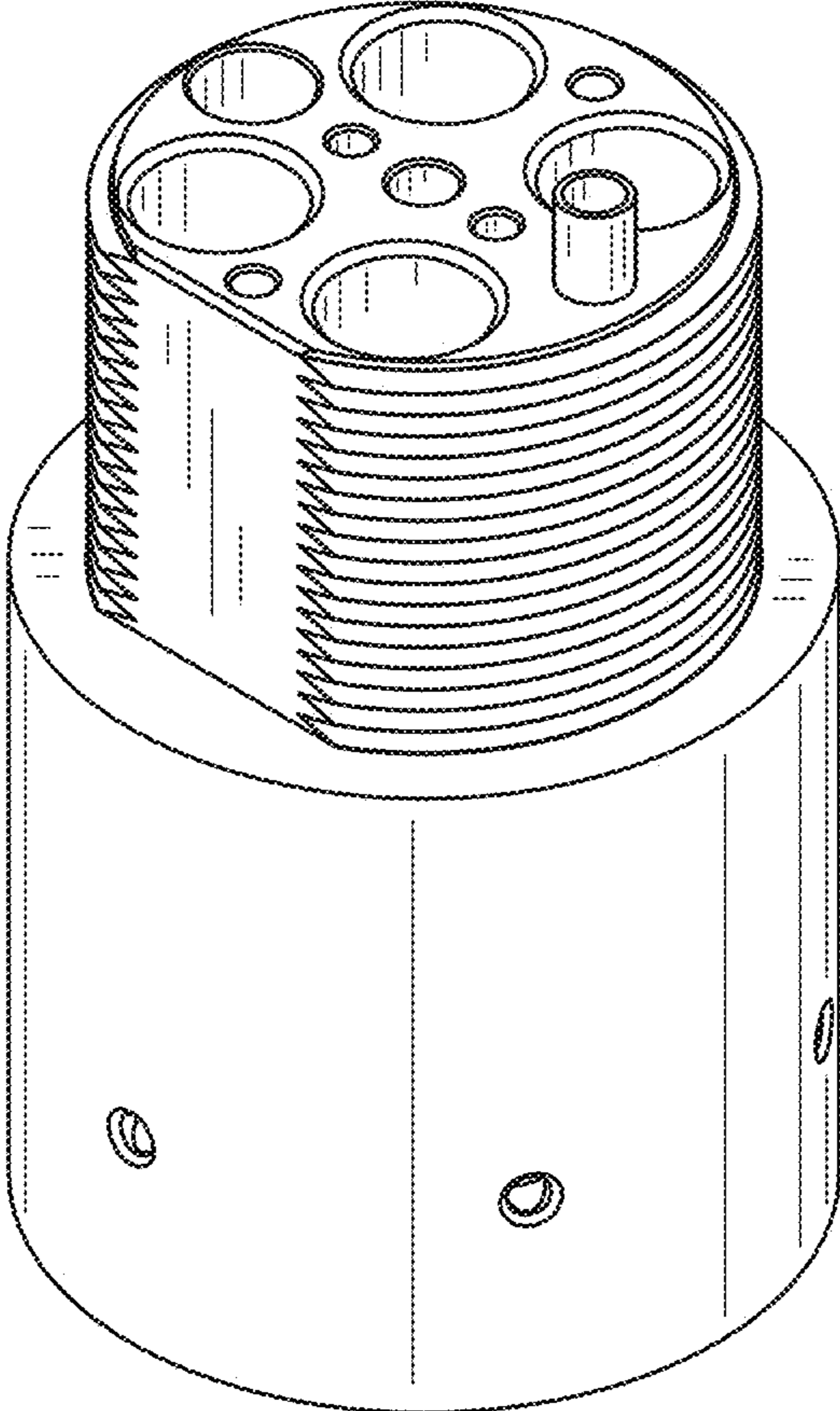


FIG.1

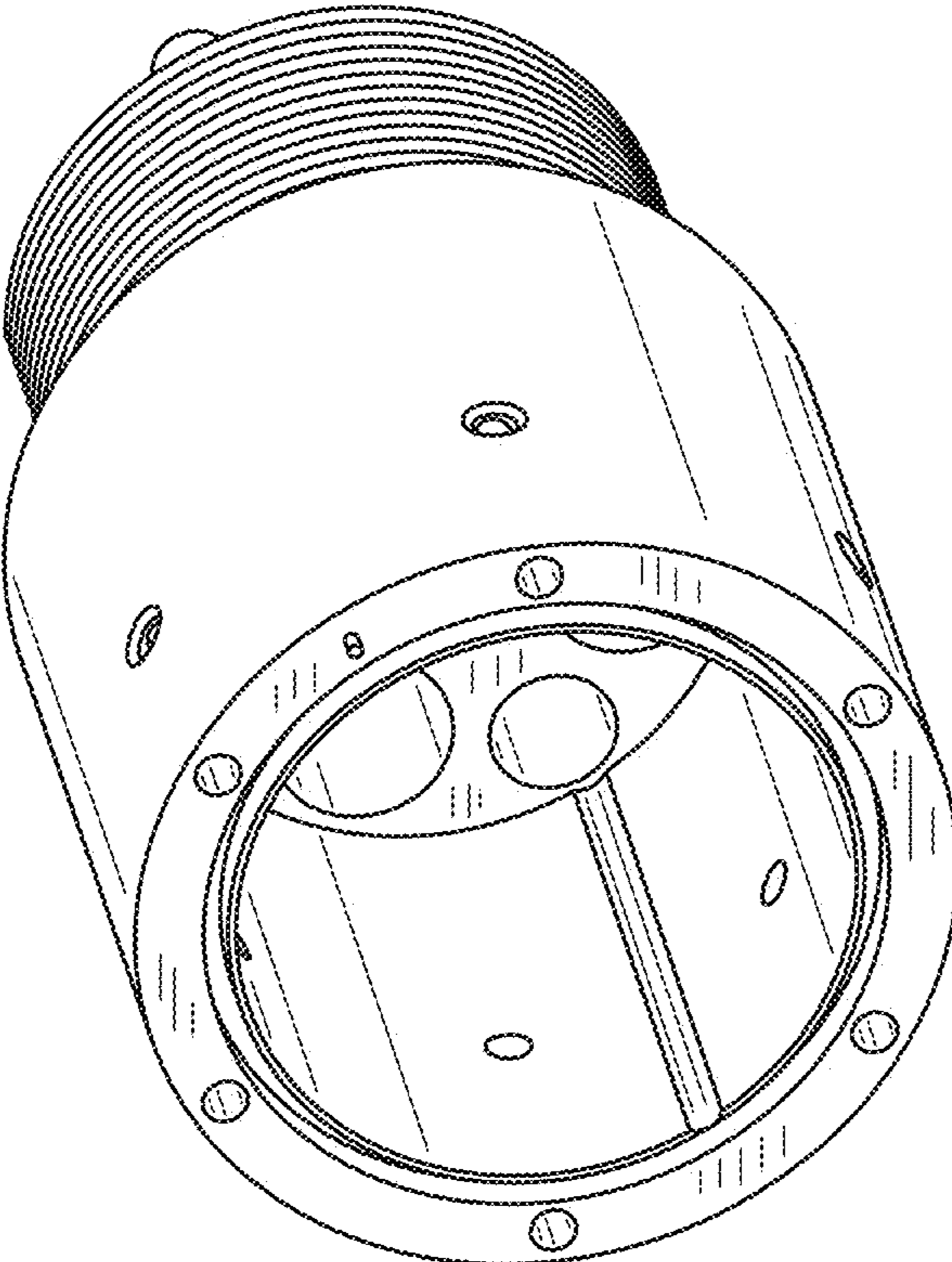


FIG.2

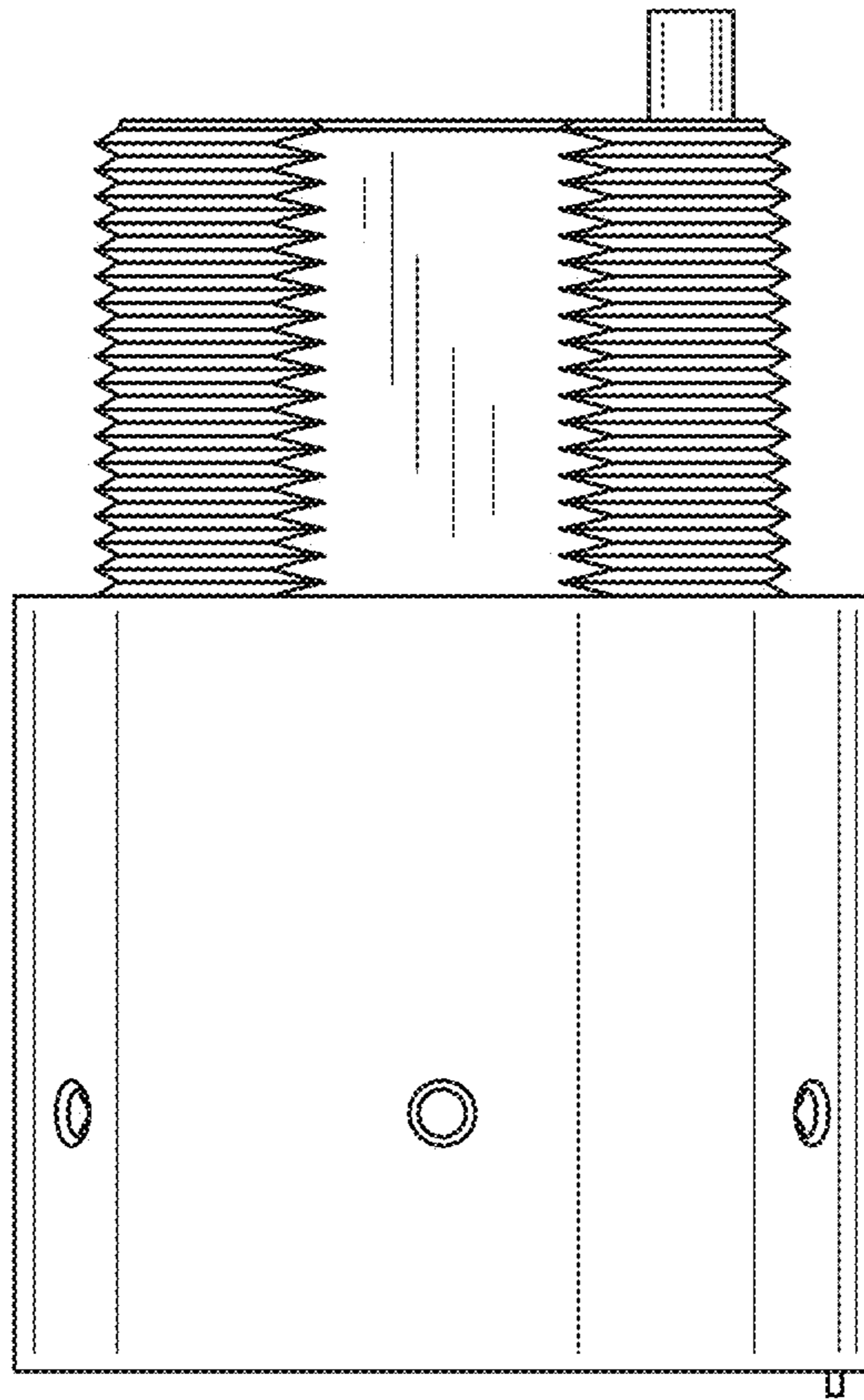


FIG.3

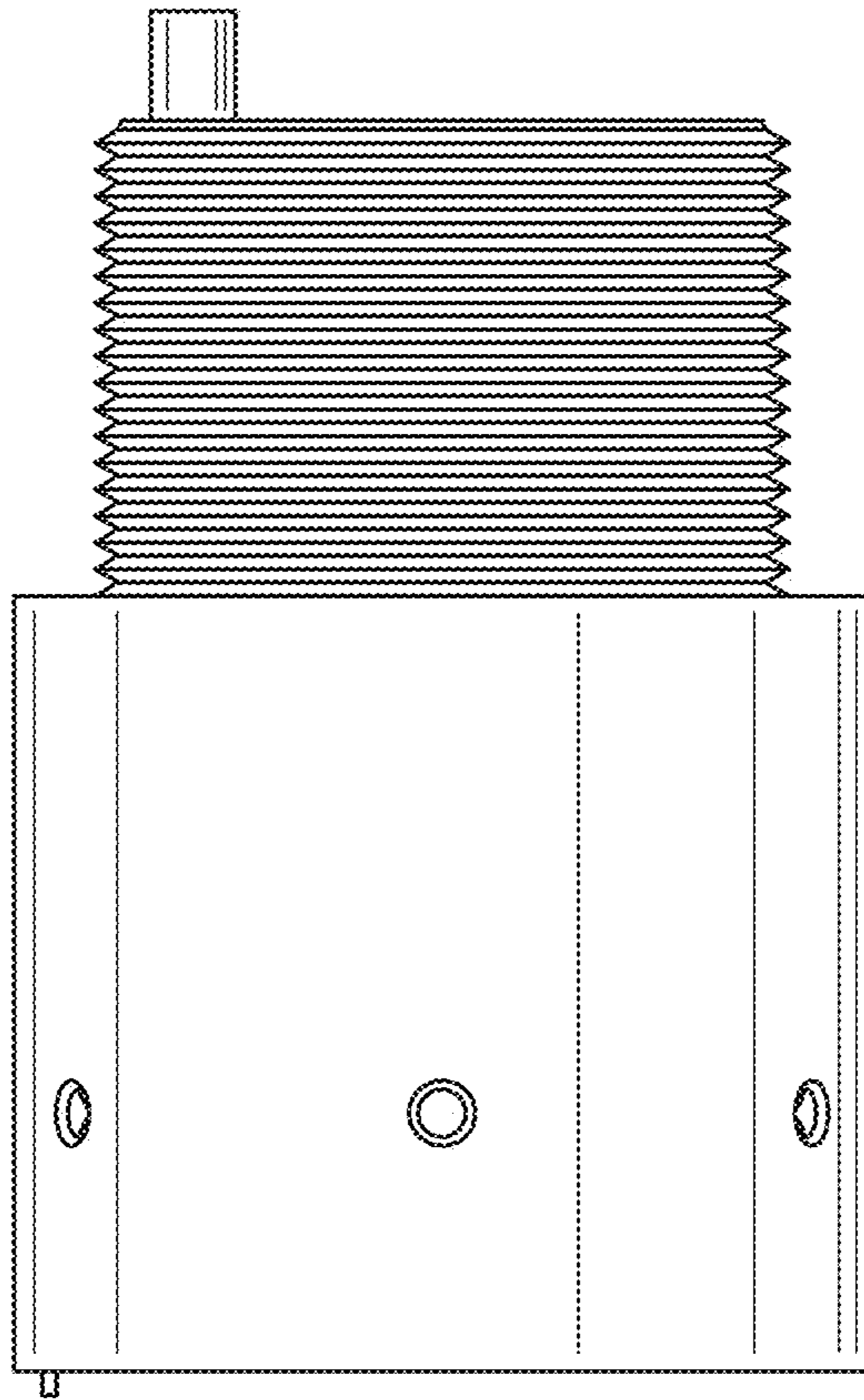


FIG.4

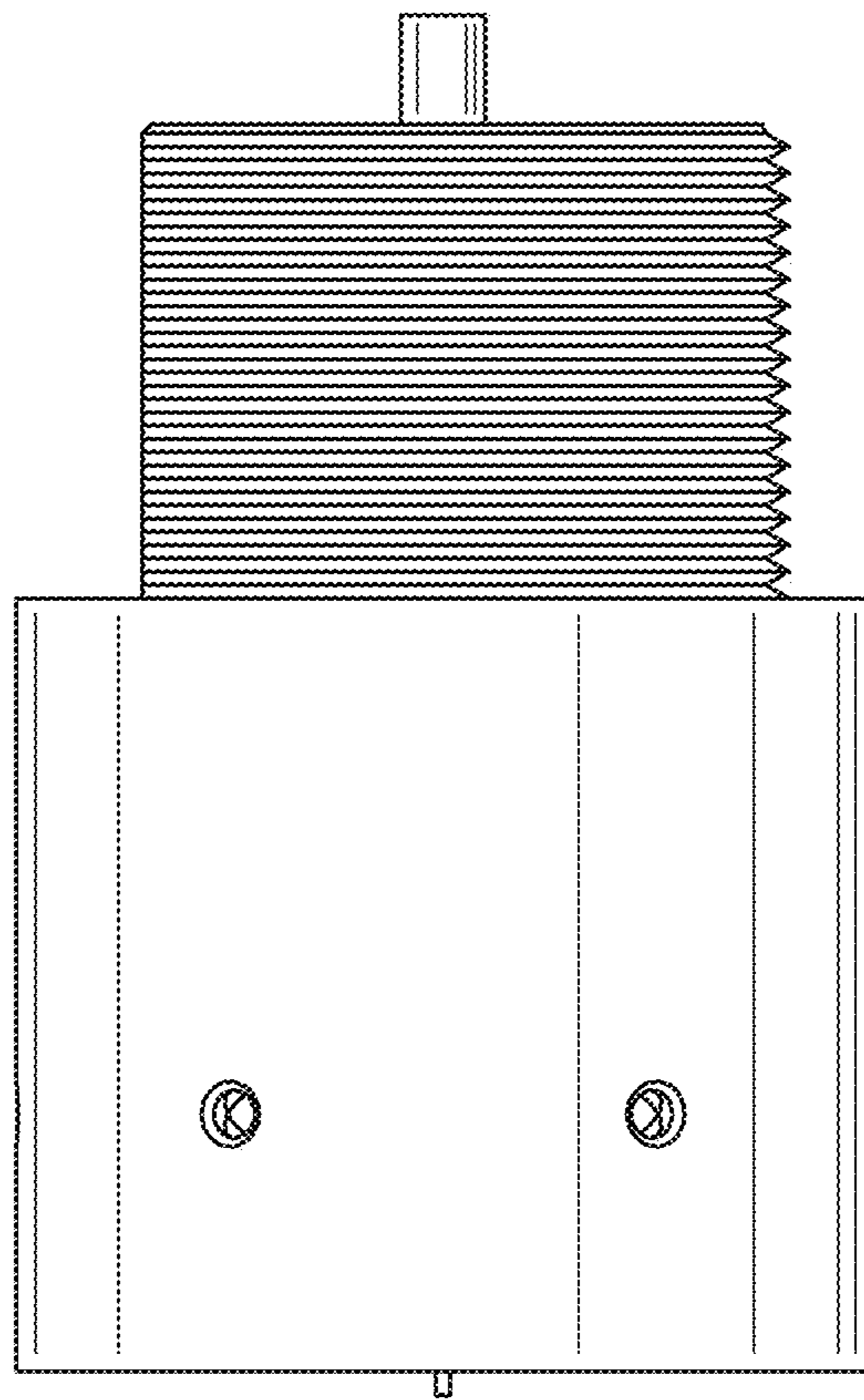


FIG.5

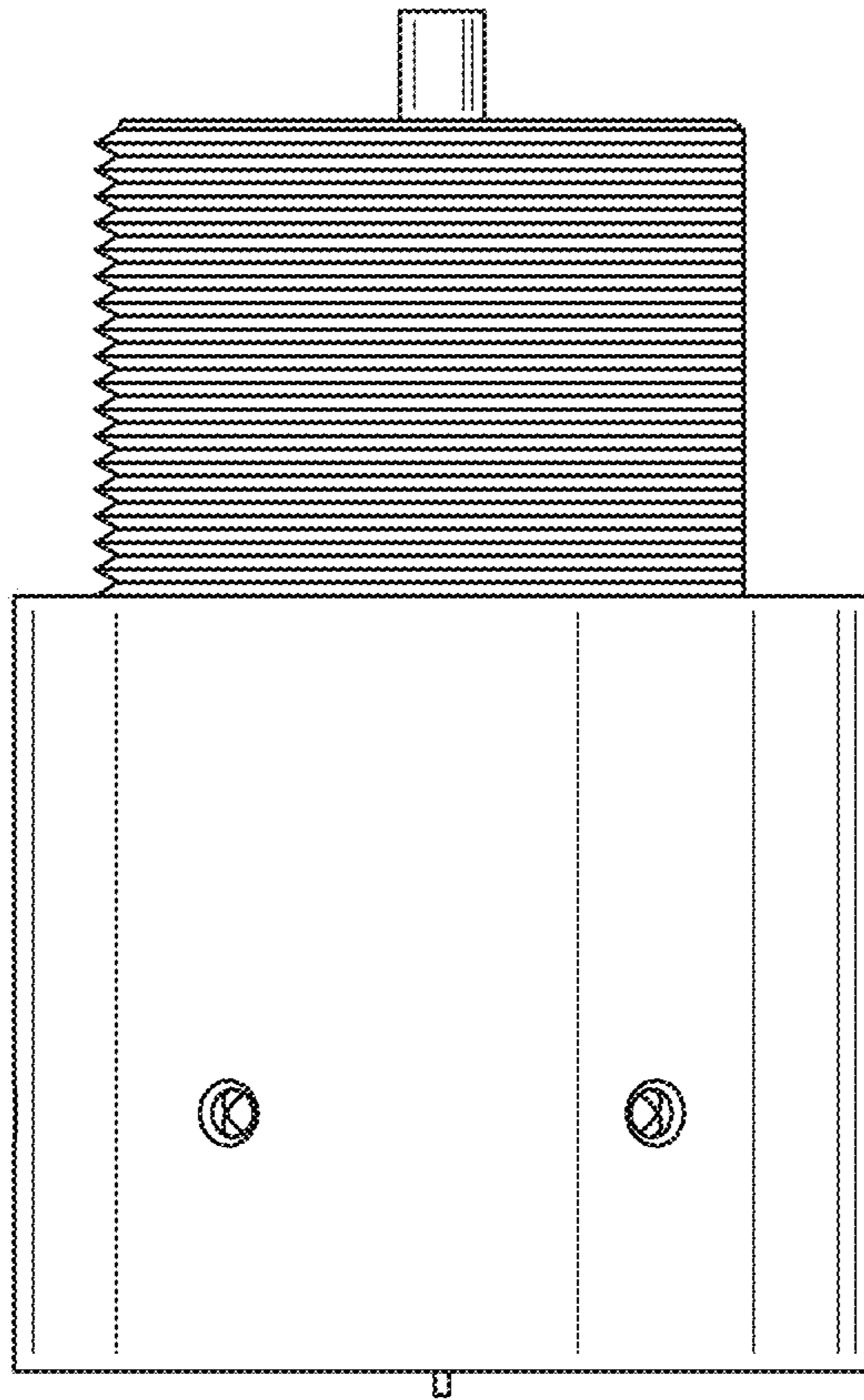


FIG.6

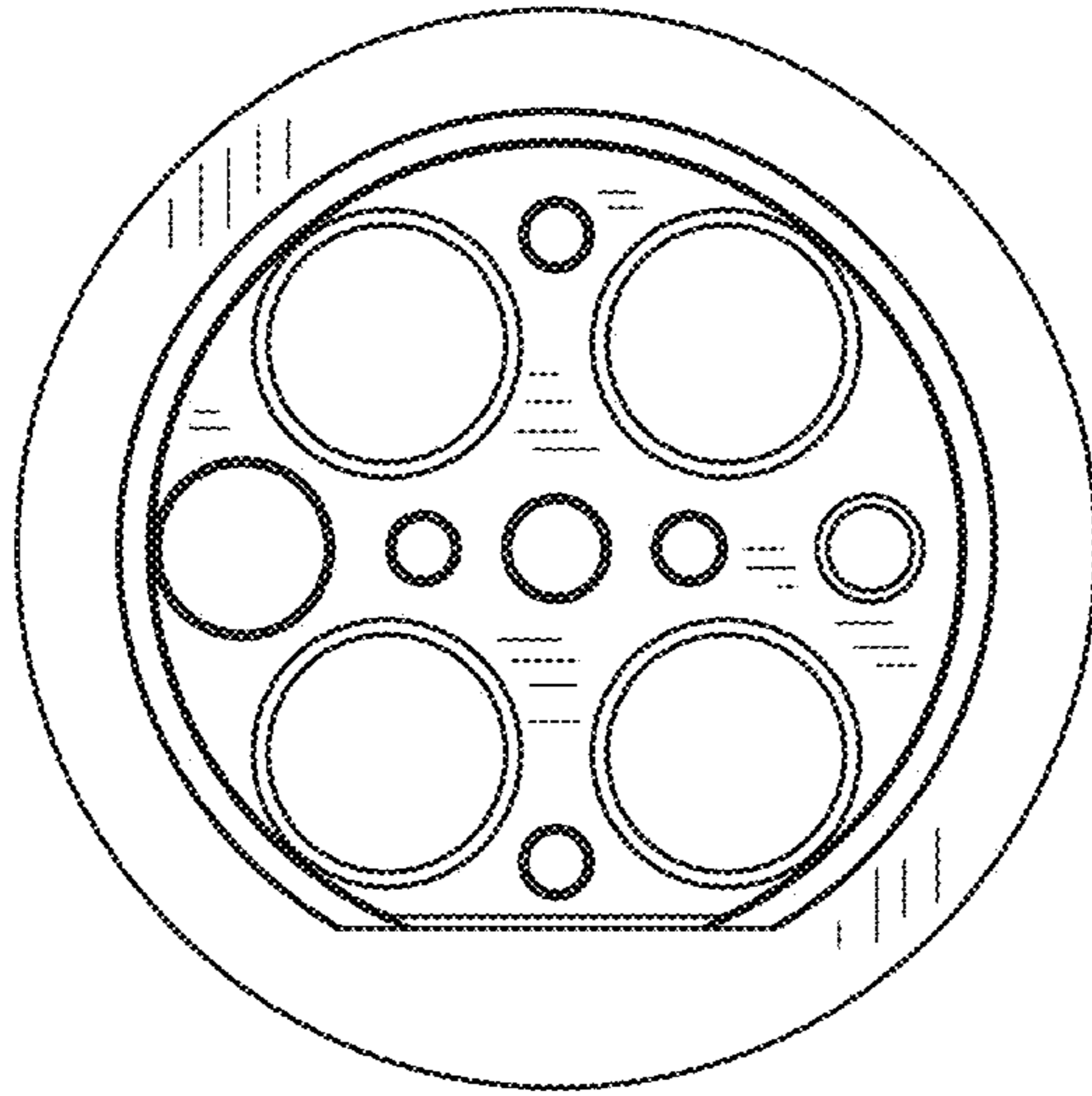


FIG.7

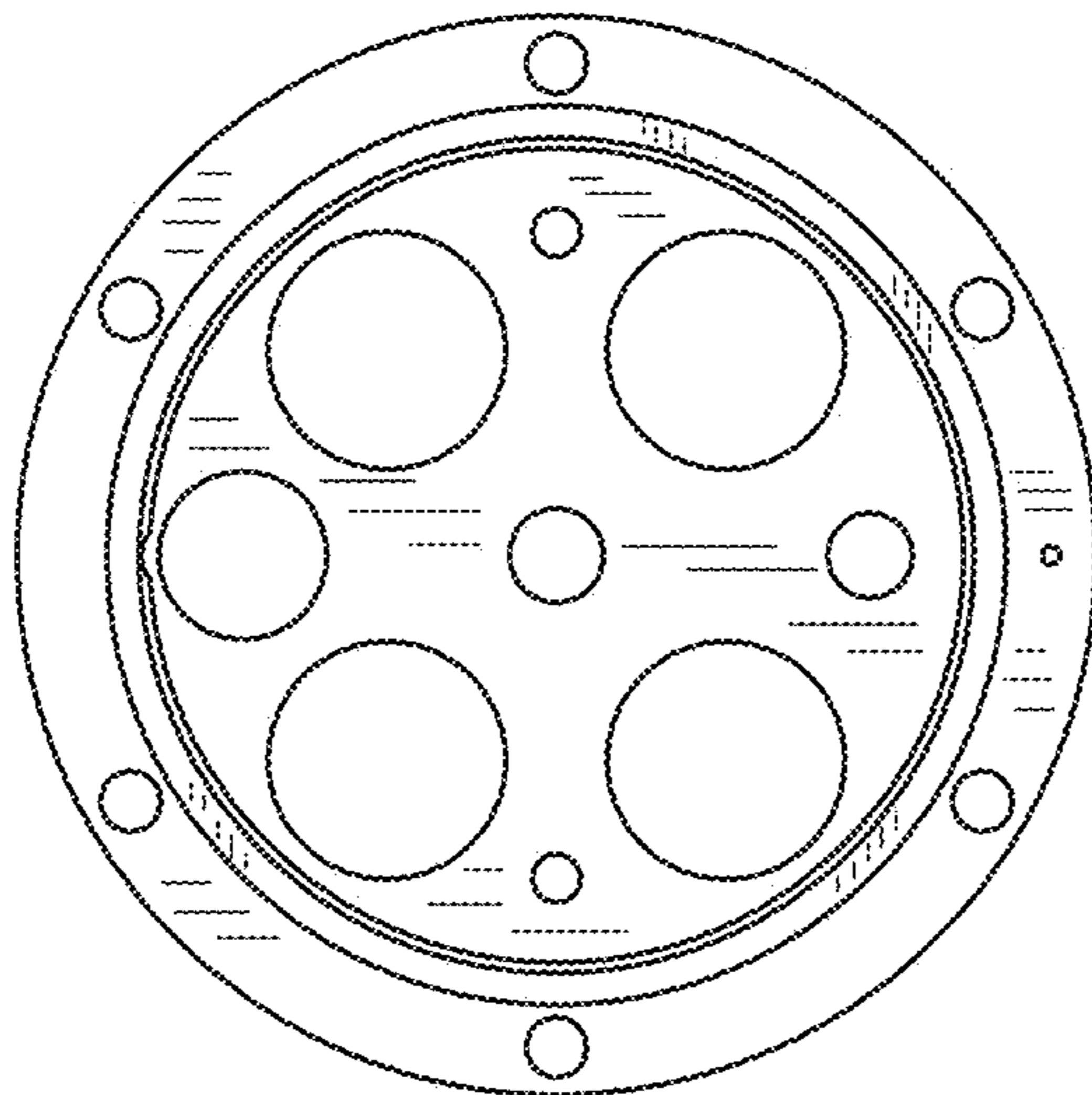


FIG.8